

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	0	"445"/\$.ccls. and (method same electron same emitting same wet same dry same (etch or etching)) and cathode and gate and electrode and (focus or focusing)	USPAT	OR	OFF	2006/03/09 08:22
L2	1	"445"/\$.ccls. and (method same electron same emitting same wet same dry same (etch or etching)) and cathode and gate and electrode and (focus or focusing)	USPAT	OR	OFF	2006/03/09 08:25
L3	1	"445"/\$.ccls. and (electron same emitting same wet same dry same (etch or etching)) and cathode and gate and electrode and (focus or focusing)	USPAT	OR	OFF	2006/03/09 08:24
L4	1	"445"/\$.ccls. and (electron same emitting same wet same dry same (etch or etching))	USPAT	OR	OFF	2006/03/09 08:24
L5	1	(method same electron same emitting same wet same dry same (etch or etching)) and cathode and gate and electrode and (focus or focusing)	USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/09 08:25
L6	6	(method same electron same emitting same wet same dry same (etch or etching)) and cathode and gate and electrode and (focus or focusing)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/09 08:29
L7	46	(electron same emitting same wet same dry same (etch or etching))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/09 08:29